

FORM PTO-1449 US DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		Any. Docket No. 81326LPK		Serial No. US 09/608,818		
If AFTER the later date of the first Office Action or 3 months from filing use only with Rule 97(E) Certificate or Fee		Applicant: Jiann H. Chen, et al				
		Filing Date June 30, 2000		Group 1773 176		
LIST OF ART CITED BY APPLICANT <small>(Use several sheets if necessary)</small>		U.S. PATENT DOCUMENTS				
Examiner <small>Initial*</small>	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE <small>IF APPROPRIATE</small>
ET	4,272,179	Jun. 9, 1981	Seanor	355	3FU	
ET	4,568,275	Feb. 4, 1986	Sakurai	432	60	
ET	4,853,737	Aug. 1, 1989	Hartley, et al	355	289	
ET	4,999,221	Mar. 12, 1991	Eigenbrod, et al	427	195	
ET	5,157,445	Oct. 20, 1992	Shoji, et al	355	284	
ET	5,547,759	Aug. 20, 1996	Chen, et al	428	421	
ET	5,582,917	Dec. 10, 1996	Chen, et al	428	421	
ET	5,595,823	Jan. 21, 1997	Chen, et al	428	421	
ET	5,599,631	Feb. 4, 1997	Chen, et al	428	421	
ET	5,919,886	Jul. 6, 1999	Matsuda, et al	525	276	
ET	5,948,479	Sep. 7, 1999	Adam, et al	427	388.4	
ET	6,020,450	Feb. 1, 2000	Matsuda, et al	528	42	
ET	6,035,780	Mar. 14, 2000	Badesha, et al	101	217	
ET	6,068,931	May 30, 2000	Adam, et al	428	469	
ET	5,464,698	Nov. 7, 1995	Chen, et al	428	421	
ET	6,041,210	Mar. 21, 2000	Chen, et al	399	333	
ET	4,373,239	Feb. 15, 1983	Henry, et al	29	132	
ET	4,430,406	Feb. 7, 1984	Newkirk, et al	430	99	
ET	4,518,655	May 21, 1985	Henry, et al	428	329	
FOREIGN PATENT DOCUMENTS						
Examiner <small>Initial*</small>	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION <small>YES NO</small>
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)						
ET	"Segmented Organosiloxane Copolymers", Polymer, 1984, V.25, pp1800-1806, by Yilgor et al.					
ET	"THV Fluoroplastic" by D.E. Hull, B.V. Johnson, I.P. Rodricks and J.B. Staley, Modern Fluoropolymers, edited by John Scheirs, 1997					
ET	"Encyclopedia of Polymer Science and Engineering", Volume 17, pps 829 – 835 on Thermoplastics and Fluoroplastics (J. Wiley & Sons 1989)					
ET	"Encyclopedia of Polymer Science and Engineering", Volume 7, pps 257 –269 on Fluorocarbon Elastomers (J. Wiley & Sons 1987)					
ET	Kirk-Othmer "Encyclopedia of Chemical Technology", Volume 8, pps 990 – 1005 on Fluorocarbon Elastomers (J. Wiley & Sons 1993)					
EXAMINER ETSO-y			DATE CONSIDERED 2-25-02			
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ET	4,970,098	Nov. 13, 1990	Ayala-Esquilin, et al	428	36.4	
ET	5,253,027	Oct. 12, 1993	Goto	355	290	
ET	5,269,740	Dec. 14, 1993	Fitzgerald, et al	492	56	
ET	5,292,606	Mar. 8, 1994	Fitzgerald	428	35.8	
ET	5,292,562	Mar. 8, 1994	Fitzgerald, et al	428	35.8	
ET	5,336,539	Aug. 9, 1994	Fitzgerald	428	36.8	
ET	5,464,703	Nov. 7, 1995	Ferrar, et al.	428	421	
ET	5,466,533	Nov. 14, 1995	Fitzgerald, et al	428	477	
ET	5,474,821	Dec. 12, 1995	Kass	428	35.8	
ET	5,474,852	Dec. 12, 1995	Fitzgerald, et al	428	447	
ET	5,480,724	Jan. 2, 1996	Fitzgerald, et al.	428	477	

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EXAMINER

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